Inhom ogeneous m etallic phase upon disordering a two dim ensional M ott insulator

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We nd that isoelectronic disorder destroys the spectral gap in a M ott-H ubbard insulator in 2D leading, m ost unexpectedly, to a new m etallic phase. This phase is spatially inhom ogeneous with m etallic behavior coexisting with antiferrom agnetic long range order. Even though the M ott gap in the pure system is much larger than antiferrom agnetic exchange, the spectral gap is destroyed locally in regions where the disorder potential is high enough to overcome the inter-electron repulsion thereby generating puddles where charge uctuations are enhanced. W ith increasing disorder, these puddles expand and concom itantly the states at the Ferm ienergy get extended leading to a m etallic phase. W e discuss the implications of our results for experiments.

D isorder can lead to new in portant phenom ena: such as localization in disordered m edia [1, 2], m etal-insulator transitions β], precisely quantized H all plateaus in the quantum H all e ect, and zero resistance from pinned vortices in a type II superconductor. In systems as diverse as superconducting lm s4], high T_c cuprates[5] and m anganites[6] disorder produces nanoscale inhom ogeneities which can have a profound in uence on the properties of these system s.

We propose the existence of a new metallic phase at T = 0 which is generated when potential disorder is introduced into a M ott insulator. This metallic phase is highly inhom ogeneous and coexists with long range antiferrom agnetic order. It is sandwiched between two qualitatively di erent insulators: at low disorder, a M ott insulator with a spectral gap and antiferrom agnetic (AFM) long range order, and, at high disorder, a param agnetic A nderson insulator with gapless excitations. Our result is surprising since one would expect that the prim ary role of disorder is to localize wave functions, which is opposite to the conditions for form ing extended states necessary for metallic behavior.

We nd that the route to the form ation of a metal at interm ediate disorder is the following: Given a random potential pro le, there are two types of regions: weakly disordered (WD) with relatively small potential uctuations and strongly disordered (SD) with larger uctuations. AFM order exists in the W D regions that consist of singly occupied sites with a large local M ott gap. On the other hand, in the SD regions the local density deviates from one per site which disrupts the antiferrom agnetic ordering and also leads to the collapse of the gap locally. There is thus a phase separation' between the insulating AFM WD regions and the metallic SD regions with suppressed AFM . The low lying excitations of the system remain trapped in the SD regions. With increasing disorder the SD regions grow and along with that, the eigenfunctions get extended throughout the system and the system becomes metallic at intermediate disorder. At high disorder the system becom es a param agnetic Anderson insulator. We substantiate the above picture

with calculations of the magnetic correlations, the local density of states and the optical conductivity.

W e propose that experiments on cuprates in their parent M ott insulating phase, could introduce disorder by isoelectronic substitution, or by bom bardment, without changing the carrier doping. Such experiments should be able to see this unusual metallic phase at intermediate disorder. Recently, Vajk et. al[7] have measured the spin correlations using neutron scattering in La_2CuO_4 with Z n substitution on the Cu sites. It will be necessary to complement the magnetic information from neutron scattering with transport and spectroscopy to look for signatures of an inhom ogeneous metallic phase.

M odel and Calculation: W e m odel the 2D disordered M ott insulator by a repulsive H ubbard m odel at half lling (one electron per site) with potential disorder:

$$H = K + U \qquad \begin{array}{c} X & X \\ n_{i''}n_{i\#} + & (V_i)n_i : \\ i & i; \end{array}$$
(1)

P t $_{(ij)}$; ($c_i^y c_j + h c$:) is the kinetic energy, c_i^y K = (ci) the creation (destruction) operator for an electron with spin on a site ri of a square lattice of N sites, t the near-neighbor hopping, U is the on-site repulsion between electrons, $n_i = c_i^y c_i$, and the chemical potential. The random potentialVi is chosen independently at each ri and is uniform ly distributed in the interval [V;V];V thus controls the strength of the disorder. All energies are measured in units of t. This is a minimal m odel containing the interplay of electronic correlations and localization: for zero disorder V = 0 it describes a M ott insulator at half lling, and for U = 0 it reduces to the (non-interacting) Anderson localization problem . W e report results for U = 4t and lattices up to 50 50.

The dynam ical mean eld theory [] has been widely used to study M ott insulators and includes the quantum uctuations associated with an e ectively single site approxim ation of the system. The inhom ogeneous H artree Fock approxim ation that we im plem ent here is a com plem entary m ethod which does not contain the dynam ical uctuations but, when solved self consistently as we do

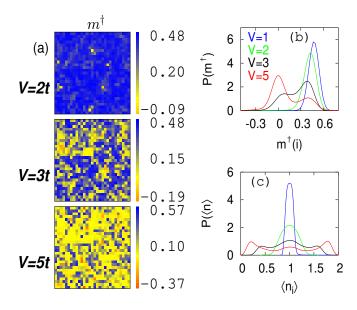


FIG.1: (a) Left panels show the local staggered magnetization m^Y(i) hS_z (i)i(1)^{i_x+i_y}. The regions in blue have AFM order; the defective sites with reduced AFM order are shown in yellow and red. The data is for the disordered H ubbard m odel at half lling with U = 4t on a 28 28 lattice for disorder strengths V = 2t; V = 3t; V = 5t for one realization of disorder. (b) P robability distribution P (m^Y) of m^Y(i) for di erent values of V. For V = 1, P (m^Y) has a peak near 0.4. With increasing V, P (m^Y) gets broader and develops weight near 0 indicating the growth of param agnetic regions. (c) P robability distribution P (n) of the site-occupancy hn_ii for di erent values of V. For V = 1, P (n) has a peak near an average single site occupancy hn_ii 1. W ith increasing V, P (n) gets broader and develops weight for doubly occupied and unoccupied sites.

here, captures the inhom ogeneity in the spatial structure of the electronic density, a feature which is at the heart of problem s with disorder. The only known way to include both the spatial and tem poral uctuations is quantum M onte Carlo (QMC) but that m ethod too has limitations arising from nite size e ects, inability to extract dynam ical inform ation without the use of com plicated maximum entropy methods and the sign problem for ferm ions that lim its the calculations to nite tem peratures. We begin by treating the spatial uctuations of the local densities $n_i = hc_i^y c_i$ i and local magnetic $eldsh_{i}^{+} =$ $Uhc_{i}^{V}c_{i}$ i and $h_{i} = Uhc_{i}^{V}c_{i}$ i using a site dependent mean eld approximation. As a consequence, we get an e ective H am iltonian which is quadratic in the ferm ion operators and can be diagonalized for a system with periodic boundary conditions. Starting with an initial guess for h_i 's and n_i 's[9] we num erically solve for the eigenvalues n and eigenvectors n (r_i) of a 2N 2N matrix. The local elds are then determined in terms of the eigenfunctions and the eigenvalue problem with these new local elds as input is then iterated until self consis-

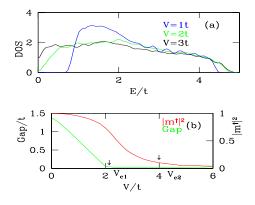


FIG.2: (a) D ensity of states averaged over 10 realizations at half lling and U = 4t for V=t = 1;2;3. For V = t there is a M ott gap in the spectrum at the chem ical potential E = 0; and for V = 2t the gap has closed. (b) Single particle energy gap as a function of V showing the collapse of the gap at V_{c1} 22t (scale on LHS). The decrease of the AFM staggered order param eter m⁹ (scale on RHS), as a function of disorder strength V and its vanishing beyond V_{c2} 4t > V_{c1} . Note that at V = 2t the system is still strongly AFM even though the M ott gap has vanished.

tency is achieved at each site.

Antiferrom agnetic Order and Spectral Gap: Fig. 1 shows that the local staggered magnetization m^Y(i) ($1j^{i_x+i_y}hS_z$ (i)i is largely antiferrom agnetic for V = 2t with a few local defective regions. W ith increasing disorder the defective regions having reduced antiferrom agnetic order grow in size.

W e next look at the behavior of the two de ning characteristics of a Mott insulator in Fig. 2: the spectral gap obtained from the lowest eigenvalue of the e ective Ham iltonian, and the AFM order parameter m^{y} (i) obtained from the spatial behavior of the spin-spin correlation function at large distances, as a function of disorder. The st surprise is that even though the energy scale for charge uctuations is U J t=U, the scale for antiferrom agnetic exchange, the spectral gap vanishes at V_{c1} 22t which is lower than the critical disorder 4t where AFM long range order (AFLRO) van-V_{c2} ishes.

The occurrence of two critical disorder strengths denes three distinct regions: In region I de ned by 0

 $V = V_{c1}$ the system is a M ott insulator with a nite gap and AFLRO. The interm ediate region II, $V_{c1} < V < V_{c2}$ is extrem ely unusual with AFLRO but no gap and is discussed in greater detail below. In region III, $V = V_{c2}$ the system is simply an Anderson or localized insulator with gapless excitations and no magnetic order.

Nature of eigenfunctions: We argue below that in region II the system is a disordered AFM metal. How does this metal come about? The spatial extent of the eigenstates near the Fermi energy in Fig. 3(a) dis-

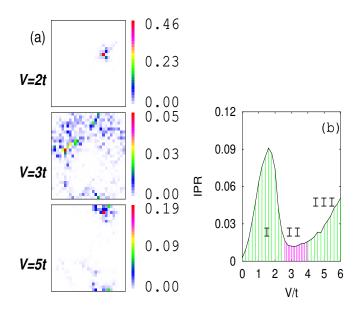


FIG. 3: (a) Single particle eigenstates at the Ferm i energy for disorder strengths V = 2t; 3t; 5t. Note that the eigenstates are localized for low V = 2t and high disorder V = 5t but surprisingly are more extended at interm ediate disorder of V = 3t. (b) Inverse participation ratio (IPR) or the localization length $\frac{2}{\log}$ for the wave function at the Ferm i energy as a function of disorder V. In both regions I and III IPR increases with disorder or \log decreases with disorder, as expected. But in the interm ediate region II, the wave function in fact gets less localized with increasing disorder.

tinctly shows that they are localized at low V = 2tand high disorder V = 5t, but quite surprisingly at interm ediate disorder V = 3t the states get m ore extended. The localization length loc () for the (norm al- $_{\rm p}(r_{\rm i})$ is related to the inverse participation ized) state $r_i j$ (r_i) $\frac{4}{j} / \frac{2}{loc}$ () [2]. One would exratio IP R pect that with increasing disorder, $_{\rm loc}$ would decrease or correspondingly IPR would increase. Instead we see in Fig.3(b) a very de nite decrease in IPR for V U = 2 sig naling that even though disorder is increasing the states are getting more extended. Such anom alous behavior 3U=4 and then once again recontinues till about V verts to the usual behavior where $\mathbb{P}R$ increases with V. Based on num erical calculations on nite size systems it is di cult to prove if the states in region II are truly extended, but what is abundantly clear is that the IPR does show a very de nite non-monotonic behavior signaling a marked change in the nature of the states, at least on m esoscopic scales.[10].

P revious QMC simulations on disordered bosonic[11] and ferm ionic[12] have shown that potential disorder that breaks particle-hole symmetry produces super uid sti – ness or conductivity which can increase with disorder. At a Hartree Fock level such an elect can be understood as a screening of the random potential by the interactions

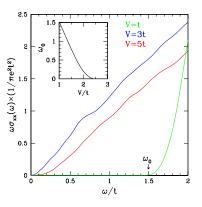


FIG.4: Frequency dependence of the conductivity for V = 1t in region I showing a gap $!_0$ in the joint density of states; for V = 3t in region II showing a linear dependence indicative of m etallic behavior; and for V = 5t in region III showing !³ dependence indicative of A nderson localization. The inset show s the decrease of the gap $!_0$ with increasing disorder V and its vanishing around $V_{\rm cl} = 2.2t$.

between the particles[15]. Our calculations go beyond simple screening arguments and have revealed the physical origin of the anom abus behavior seen in Fig. 3 at a microscopic level.

Frequency-dependent conductivity: The nature of the frequency dependent conductivity Re(!) = Im(!)=! gives insight into the conducting properties of the phases.

(!) is the Fourier transform of () = hj()j(0)i, the (disorder averaged) current-current correlation function. As shown in Fig. 4 the low frequency behavior of ! (!) has a nite gap in the M ott region I for V = t; shows a linear ! dependence in the m etallic region II for V = 3twhich in plies that there is a nite dc conductivity (! ! 0); and shows a ! ³ dependence in the Anderson insulating regim e III for V = 5t, which in plies that there are gapless excitations but nevertheless ! 0.

O rigin of the M etallic P hase: Now that we have seen evidence for a m etallic phase at interm ediate disorder, the question arises as to how such a phase com es about.

In the clean system, the repulsive interactions prevent double occupancy. But once there is potential disorder, electrons can hop into sites that have deep potential wells and thereby low er their energy. This leads to a broadened distribution of local occupancy and a grow th of param agnetic sites, as illustrated in Fig. 1. In the classical limit, sites with a large positive potential $V_i > U=2$ are unoccupied; sites with $U=2 < V_i < U=2$ are singly occupied; and sites with large negative $V_i < U=2$ are doubly occupied. Only sites with one electron can contribute to AFM order if they form a connected cluster. The critical probability p_c for classical percolation of vacancies on a 2D square lattice is $p_c = 0.41$ which should equal the density of doubly and unoccupied sites, so that $p_c = 1$ U=(2V)which in plies that $(V=U)_c = 1=2(1 - p_c) = 0.85$. This

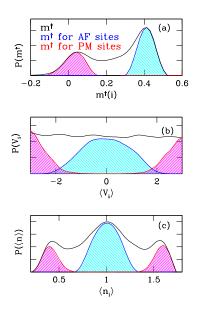


FIG. 5: (a) H istogram P (m $^{\text{y}}$) of the local staggered m agnetization (black). W e will de ne those sites with staggered m agnetization 0.38 and m ore to be AFM sites (region show n in blue); and sites with MS_z (i)i in the range (-0.1,0.1) to be param agnetic PM sites (show n in red). (b) H istogram P (V) of the local disorder potential for all sites (black); histogram of AFM sites (blue) which coincide with the less disordered W D regions; and histogram of PM sites (red) in the SD regions. (c) H istogram P (n) of the local density for all sites (black); for AFM sites (blue); and for PM sites (red).

indicates that an estimate of V_{c2} 3:4t for U = 4t. We have compared our results for m^{γ} as a function of V with the percolation of vacancies in a quantum H eisenberg m odel and nd very good agreem ent [3, 14].

Fig. 5, which shows the correlation between the strength of disorder and the nature of the regions, is very revealing. It clearly shows a reorganization or a phase separation of the system into W D regions that are AFM and have a local density of one electron per site, and the SD regions which are PM with a bim odal density clustering towards zero and two per site. Our results for the existence of metallic behavior in 2D is even more surprising when we recall the scaling theory of localization for non-interacting electrons[1] which claims that in dim ensions less than and equal to two all the single particle states are localized by arbitrarily sm all am ounts of disorder. Thus the underlying picture that emerges for the origin of the unusual metal at intermediate disorder in a M ott insulator at half lling is a percolation of the defected SD regions with reduced AFM . As seen in Fig. 3 (a) (top panel) the lowest excitations live in these defected SD regions and with increasing disorder the defective regions expand and along with that the excitations get m ore delocalized as they are able to travel on the expanding SD clusters, see Fig.3(a) (m iddle panel). This is a rather remarkable situation that increasing disorder in a correlated system is able to induce m etallic behavior. W ith further increase of disorder the states on the percolating cluster get localized and the system becomes an Anderson insulator, see Fig.3(a) (bottom panel).

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